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(12) **United States Design Patent**  
**Hieger**

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(54) **HAT HAVING A PATTERN RESEMBLING  
BASEBALL STITCHING**

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(52) **U.S. Cl.**  
USPC ..... **D2/869**

(58) **Field of Classification Search**  
USPC ..... D2/865, 869, 870, 872, 876, 882, 891,  
D2/895; D29/102, 105, 106  
CPC .. A42B 1/00; A42B 1/004; A42B 1/02; A42B  
1/04; A42B 1/041; A42B 1/062; A42B  
1/24; A42B 1/225; A42B 1/248; A42C  
5/00

See application file for complete search history.

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(57) **CLAIM**

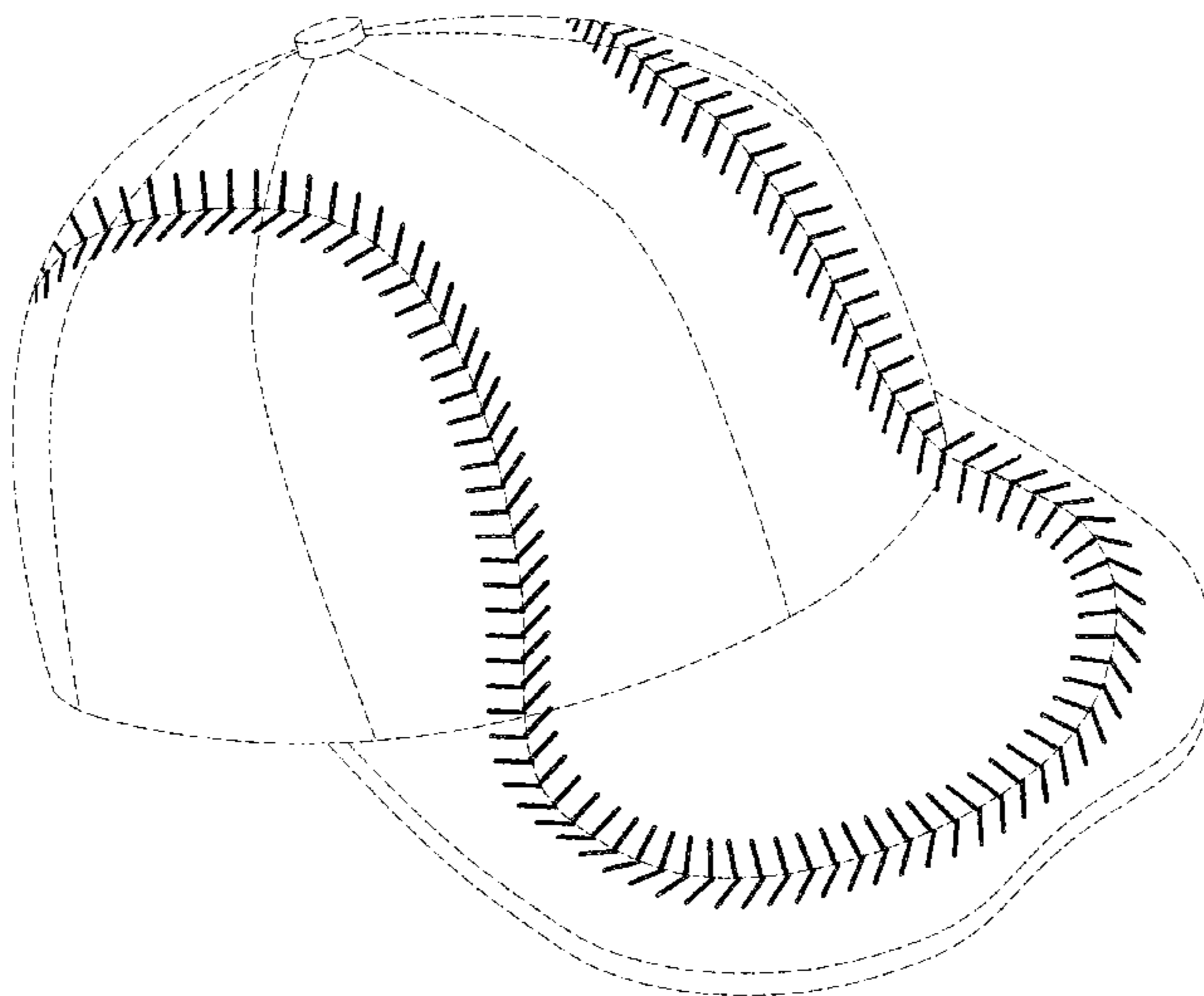
The ornamental design for a hat having a pattern resembling  
baseball stitching, as shown and described.

**DESCRIPTION**

FIG. 1 is a front perspective view of a hat having a pattern  
resembling baseball stitching of my new design;  
FIG. 2 is a front elevation view of the hat having the pattern  
resembling baseball stitching;  
FIG. 3 is a rear elevation view of the hat having the pattern  
resembling baseball stitching;  
FIG. 4 is a left side elevation view of the hat having the  
pattern resembling baseball stitching;  
FIG. 5 is a right side elevation view of the hat having the  
pattern resembling baseball stitching; and,  
FIG. 6 is a top plan view of the hat having the pattern  
resembling baseball stitching.

The broken lines in FIGS. 1-6 are directed to environment,  
including a body of the hat and seams on the body of the hat,  
including a seam extending along the pattern. The broken  
lines and environment form no part of the claimed design.

**1 Claim, 6 Drawing Sheets**



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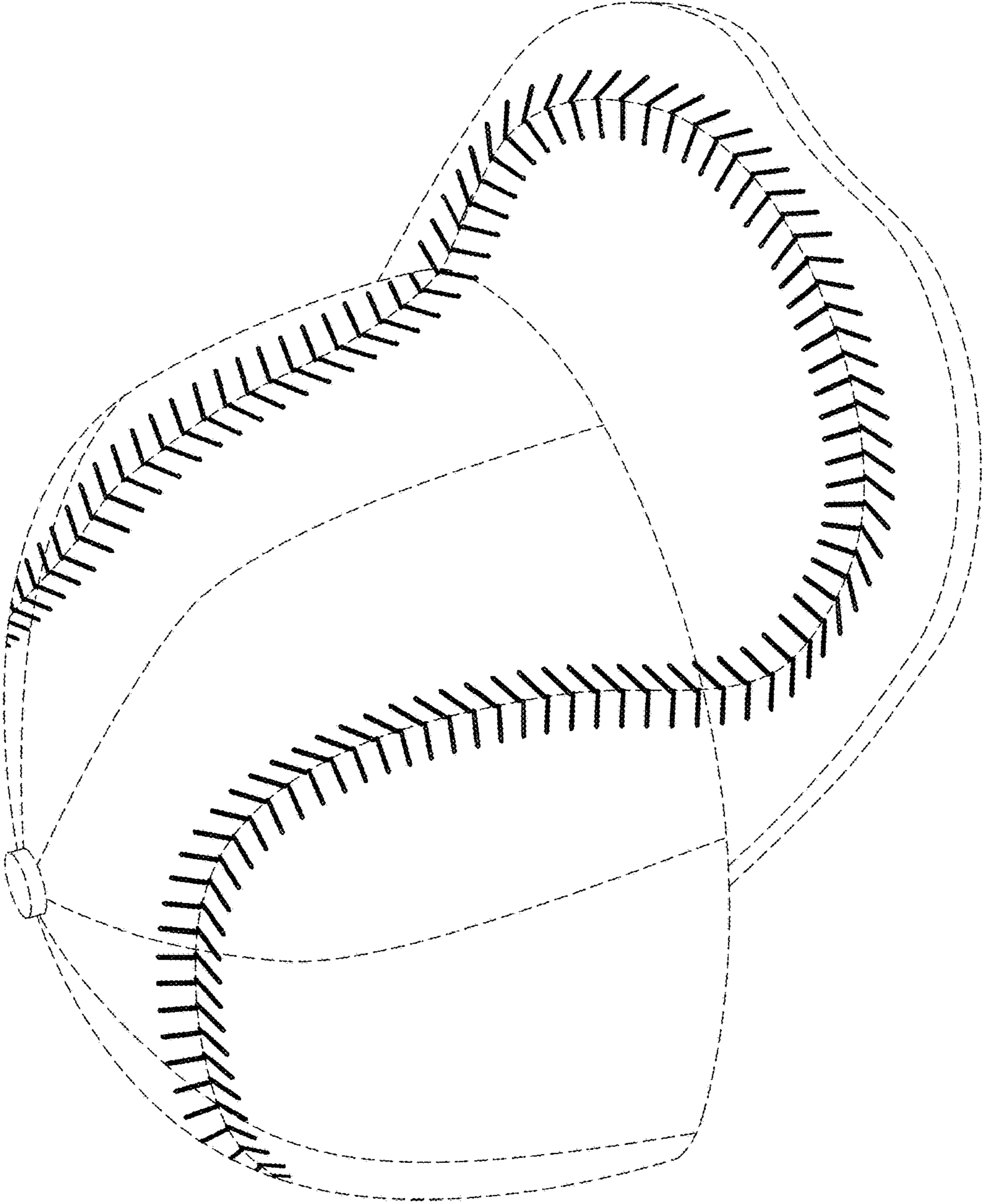


FIG. 1

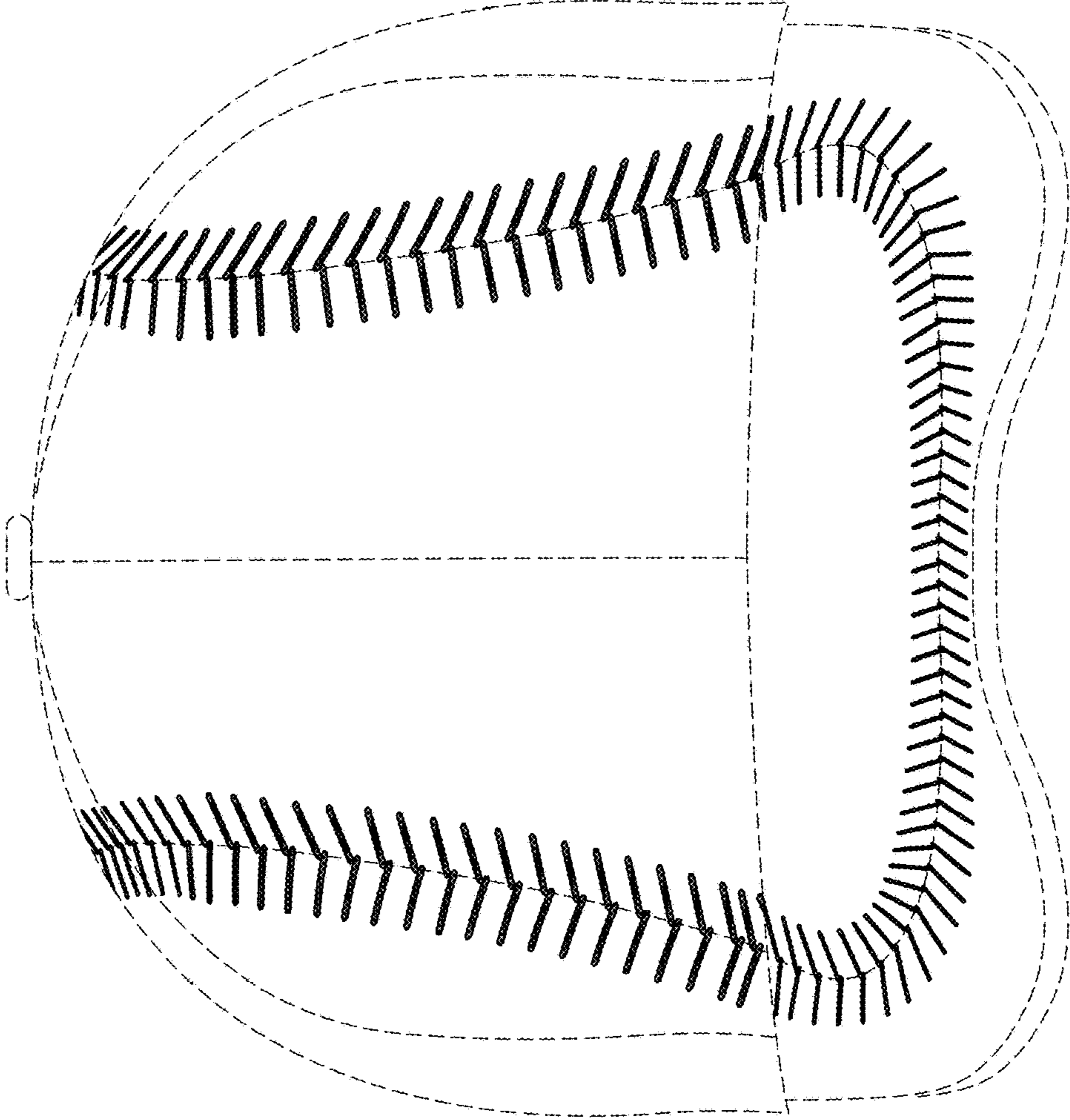


FIG. 2

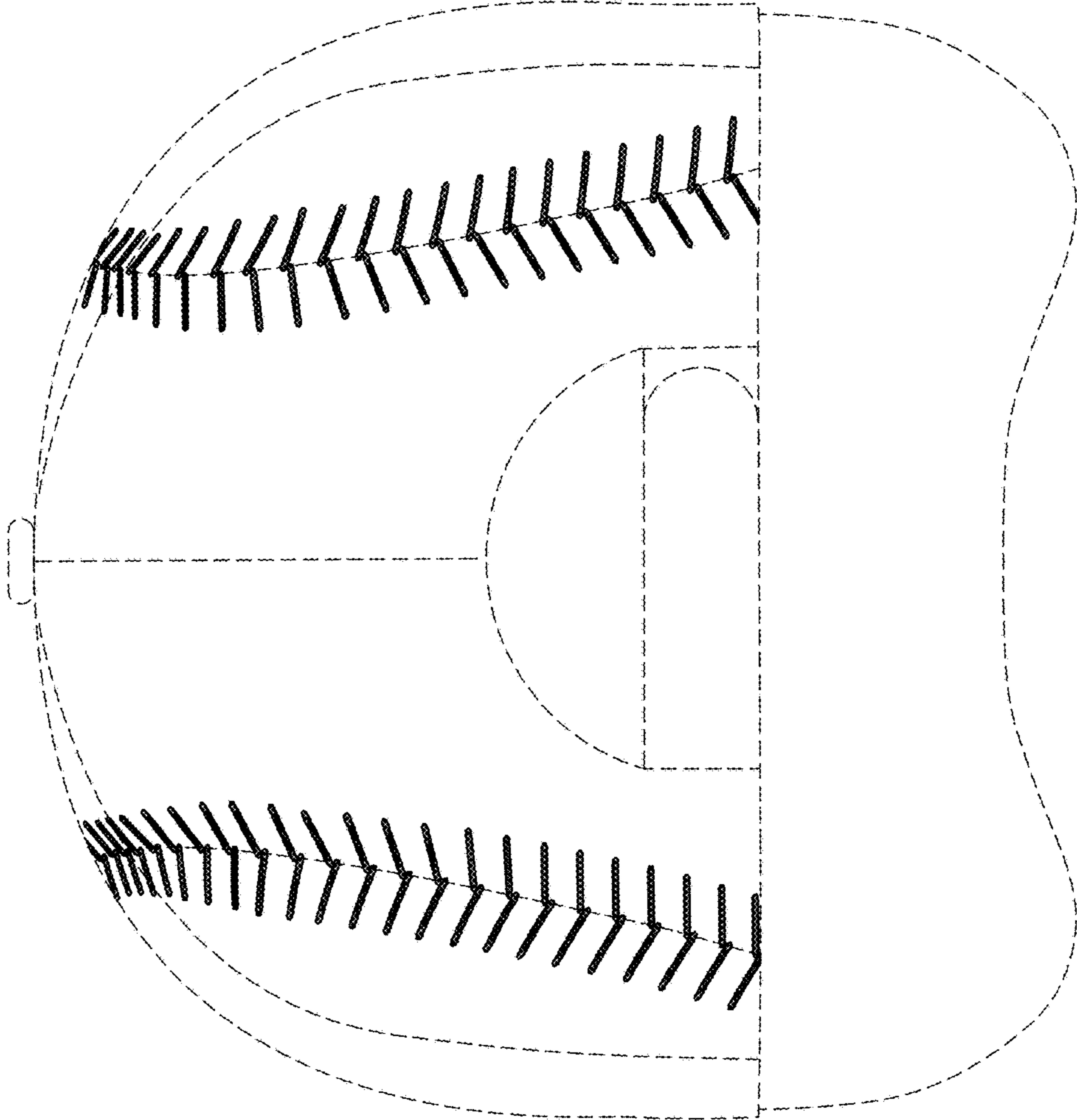


FIG. 3

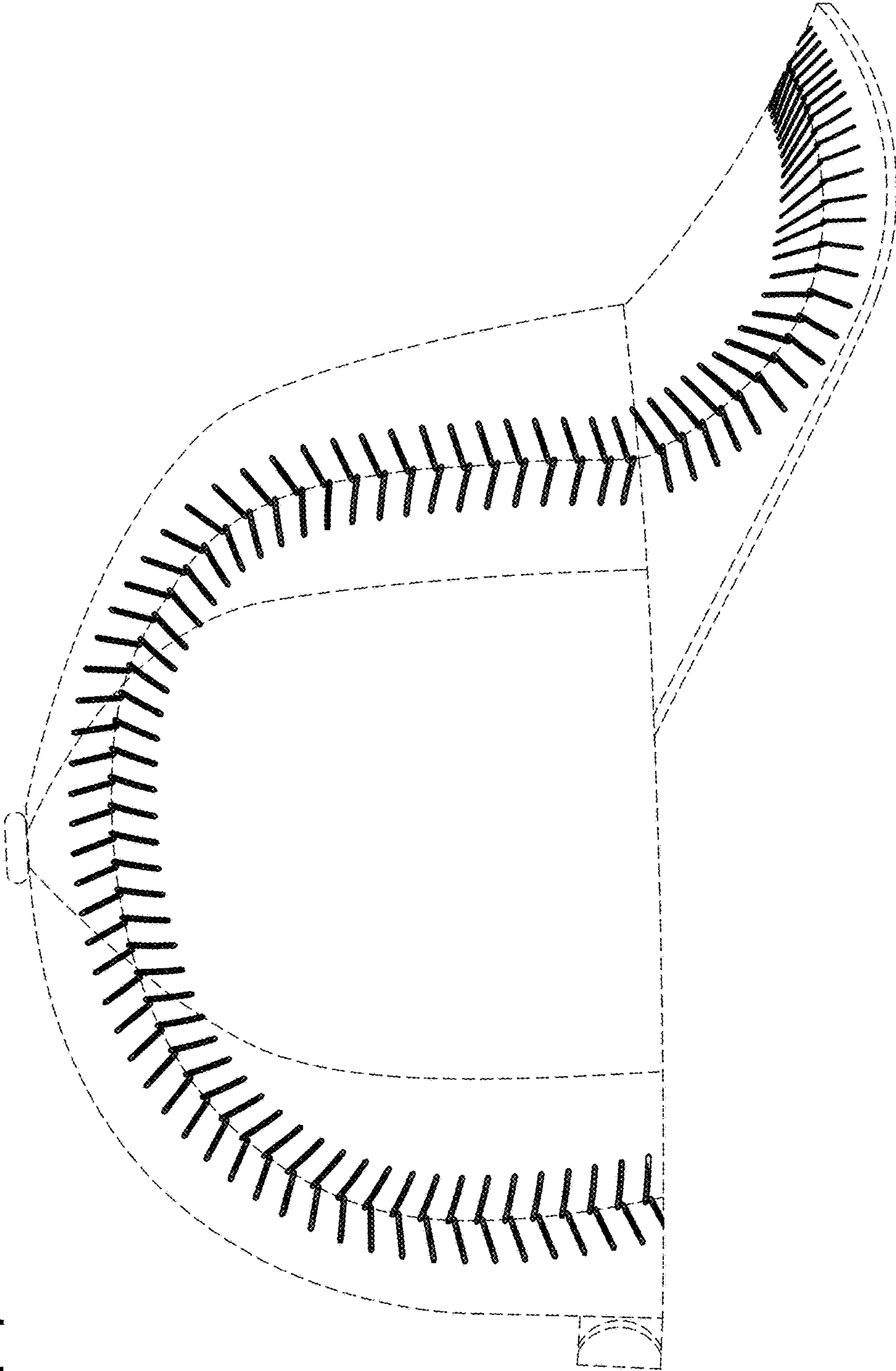


FIG. 4

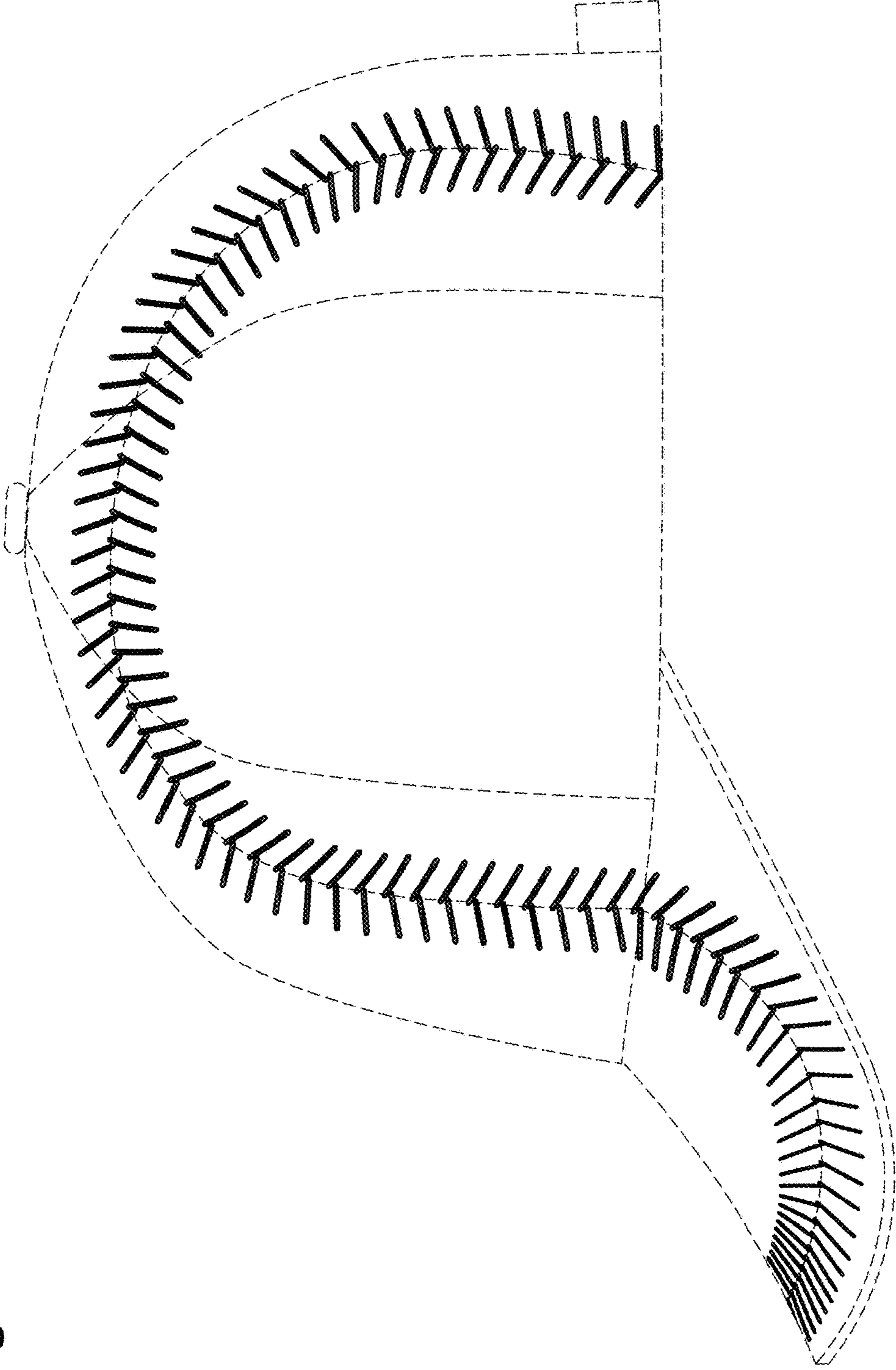


FIG. 5

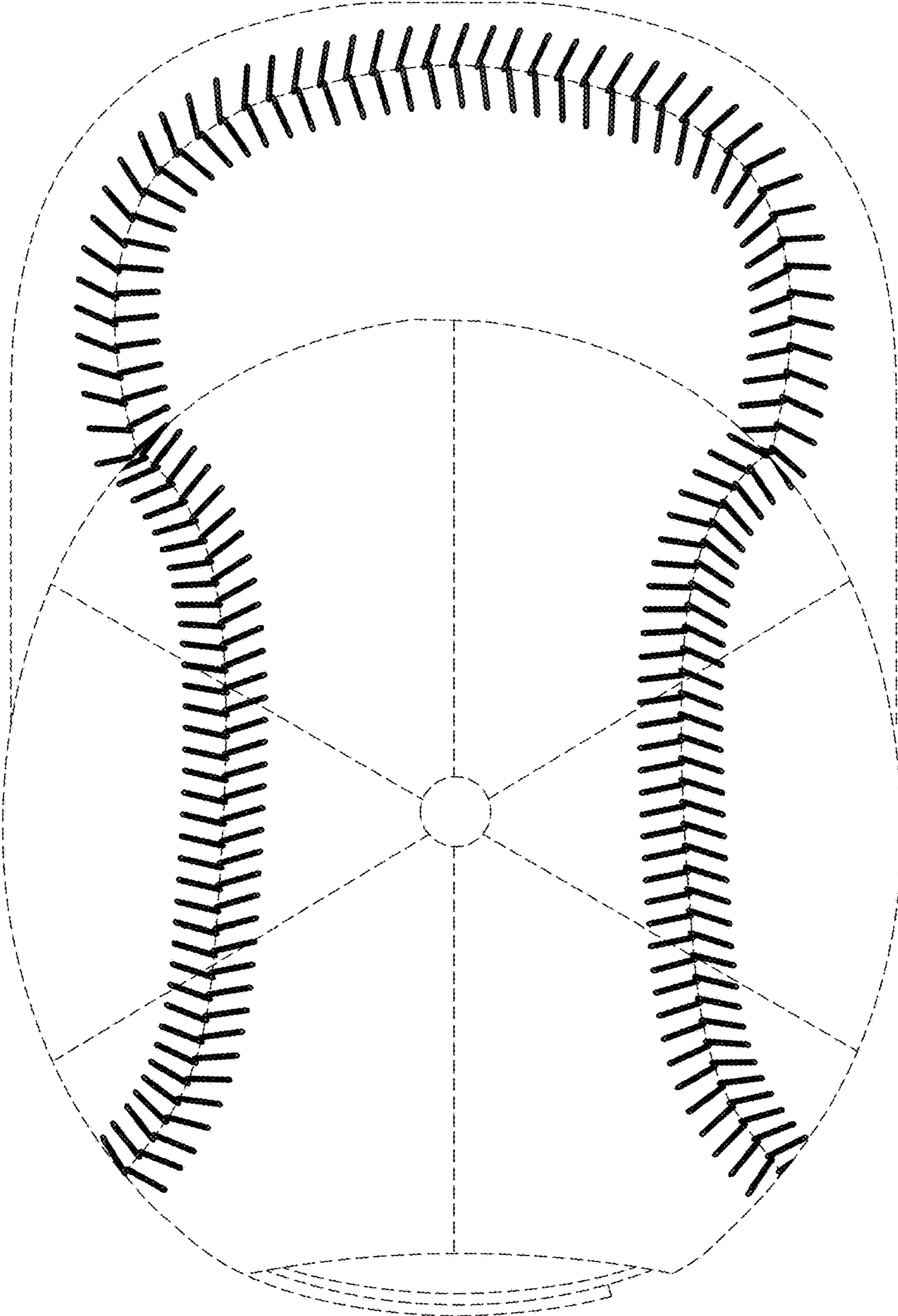


FIG. 6